


<b>Search Notes</b>  	<b>Application/Control No.</b>  10824337	<b>Applicant(s)/Patent Under Reexamination</b>  SATO, TATSUHIRO
	<b>Examiner</b>  Nguyen, Phu H	<b>Art Unit</b>  1731

<b>SEARCHED</b>			
<b>Class</b>	<b>Subclass</b>	<b>Date</b>	<b>Examiner</b>
65	31	11/14/06	P.N

<b>SEARCH NOTES</b>		
<b>Search Notes</b>	<b>Date</b>	<b>Examiner</b>
quartz adj glass adj jig.clm. and etching	12/05/2006	P.N
quartz adj glass and (fire abrasion) and annealing and etching	11/16/2006	P.N
(vapor gas) adj phase adj (etching purif\$8) amd 65/\$.ccls.	12/05/2006	P.N
see East Search History	6/8/2007	P.N
see updated East Search History	11/1/2007	P.N

<b>INTERFERENCE SEARCH</b>			
<b>Class</b>	<b>Subclass</b>	<b>Date</b>	<b>Examiner</b>